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## **Oxyfluoride Phosphors for Use in White Light LEDs**

Tech ID: 23416 / UC Case 2009-704-0

### **BRIEF DESCRIPTION**

BACKGROUND

A novel Ce3+-doped oxyfluoride phosphor material for solid-state lighting applications.

# **INVENTORS**

**KEYWORDS** 

- DenBaars, Steven P.
- ▶ Im, Won Bin
- Seshadri, Ram

### OTHER INFORMATION

phosphor, white light, LED,

indphosphor, indssl, cenIEE,

oxyfluoride, indfeat, indadvmat

White light generation for most commercial light emitting diode (LED) lamps employ yellow Ce3+ phosphors excited by blue InGaN diodes due to their unsurpassed efficiency. However, the Ce3+ phosphors have relatively weak emissions in the red region. Moreover, the color output from these phosphors is strongly dependent on temperature and current, creating problems for high power LEDs.

### DESCRIPTION

Researchers at the University of California, Santa Barbara have invented a novel Ce3+-doped oxyfluoride phosphor material for solid-state lighting applications. This invention produces much higher photoluminescence intensities than commercial Ce3+, allowing for tunability of emission color and excitation band, resulting better light quality with high efficiency. Moreover, this material can be used for white light generation with a number of phosphor combinations (near UV light with red, green-orange or yellow phosphors) and allows for greater color rendering.

# **CATEGORIZED AS**

Energy

- Lighting
- Other
- Materials & Chemicals
  - ▶ Other

**RELATED CASES** 2009-704-0, 2010-022-0

### **ADVANTAGES**

- High efficiency
- Good color rendering properties •

· Variety of applications

### **APPLICATIONS**

- LEDs
- Liquid Crystal Displays

This technology is available for licensing. Click here to request more information.

### **PATENT STATUS**

Country	Туре	Number	Dated	Case
United States Of America	Issued Patent	8,344,611	01/01/2013	2009-704

#### ADDITIONAL TECHNOLOGIES BY THESE INVENTORS

- ▶ Vertical Cavity Surface-Emitting Lasers with Continuous Wave Operation
- Eliminating Misfit Dislocations with In-Situ Compliant Substrate Formation
- Aluminum-cladding-free Nonpolar III-Nitride LEDs and LDs
- ▶ Low-Cost Zinc Oxide for High-Power-Output, GaN-Based LEDs (UC Case 2010-183)
- Defect Reduction in GaN films using in-situ SiNx Nanomask
- Enhanced Light Extraction LED with a Tunnel Junction Contact Wafer Bonded to a Conductive Oxide
- Low Temperature Deposition of Magnesium Doped Nitride Films
- ► Transparent Mirrorless (TML) LEDs
- Optimization of Laser Bar Orientation for Nonpolar Laser Diodes
- Stand-Alone Ceramic Phosphor Composites for Laser-Excited Solid-State White Lighting
- Method for Enhancing Growth of Semipolar Nitride Devices
- Ultraviolet Laser Diode on Nano-Porous AlGaN template
- Improved Reliability & Enhanced Performance of III-Nitride Tunnel Junction Optoelectronic Devices
- Improved Fabrication of Nonpolar InGaN Thin Films, Heterostructures, and Devices
- Growth of High-Quality, Thick, Non-Polar M-Plane GaN Films
- ▶ Technique for the Nitride Growth of Semipolar Thin Films, Heterostructures, and Semiconductor Devices
- (In,Ga,AI)N Optoelectronic Devices with Thicker Active Layers for Improved Performance
- Thermally Stable, Laser-Driven White Lighting Device
- MOCVD Growth of Planar Non-Polar M-Plane Gallium Nitride
- Methods for Fabricating III-Nitride Tunnel Junction Devices
- Low-Droop LED Structure on GaN Semi-polar Substrates
- Contact Architectures for Tunnel Junction Devices
- Semi-polar LED/LD Devices on Relaxed Template with Misfit Dislocation at Hetero-interface
- Semipolar-Based Yellow, Green, Blue LEDs with Improved Performance
- Growth of Semipolar III-V Nitride Films with Lower Defect Density

- ▶ III-Nitride Tunnel Junction LED with High Wall Plug Efficiency
- ► Tunable White Light Based on Polarization-Sensitive LEDs
- Cleaved Facet Edge-Emitting Laser Diodes Grown on Semipolar GaN
- Growth of High-Performance M-plane GaN Optical Devices
- Packaging Technique for the Fabrication of Polarized Light Emitting Diodes
- Improved Anisotropic Strain Control in Semipolar Nitride Devices
- A Method To Lift-Off Nitride Materials With Electrochemical Etch
- ▶ III-V Nitride Device Structures on Patterned Substrates
- Method for Increasing GaN Substrate Area in Nitride Devices
- ▶ High-Intensity Solid State White Laser Diode
- Nitride Based Ultraviolet LED with an Ultraviolet Transparent Contact
- ▶ GaN-Based Thermoelectric Device for Micro-Power Generation
- Limiting Strain-Relaxation in III-Nitride Heterostructures by Substrate Patterning
- ▶ LED Device Structures with Minimized Light Re-Absorption
- ▶ Growth of Planar Semi-Polar Gallium Nitride
- ▶ UV Optoelectronic Devices Based on Nonpolar and Semi-polar AlInN and AlInGaN Alloys
- Defect Reduction of Non-Polar and Semi-Polar III-Nitrides
- Enhancing Growth of Semipolar (Al,In,Ga,B)N Films via MOCVD

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